

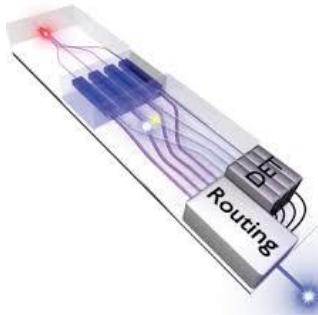
Micro- and nano-machining of transparent materials using Bessel beams

Jassem SAFIOUI, Gwenn ULLIAC, Pierre-Ambroise
LACOURT and François COURVOISIER

- jassem.safoui@femto-st.fr
- 03 63 08 23 89

How laser finds applications in industry?

femto
ENGINEERING



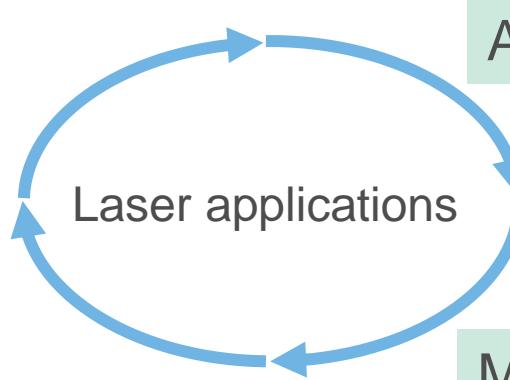
Telecommunication

3D optical circuits
Fibres cutting and welding



Security

Counterfeit
Identity documents



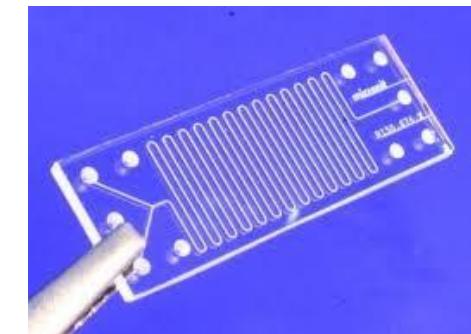
Aeronautical

Surface texturing
Fuselage

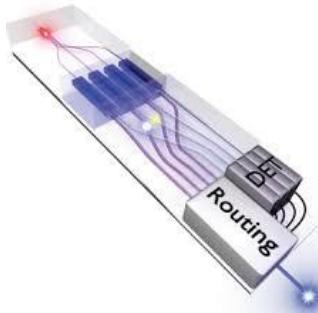


Medicine

Lab on chip
Opto-fluidic circuit



How laser finds applications in industry?



Telecommunication

3D optical circuit
Fibers cutting and welding



Security

Counterfeit
Identity documents

An important part is
occupied by transparent
materials

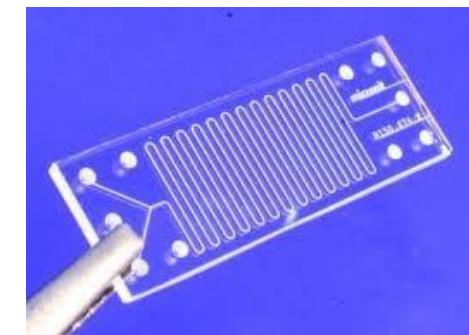


Aeronautical

Surface texturing
Fuselage

Medicine

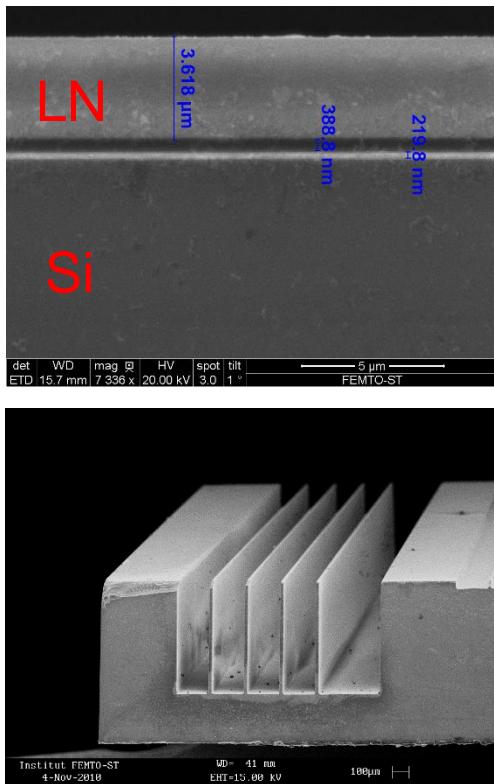
Lab on chip
Opto-fluidic circuit



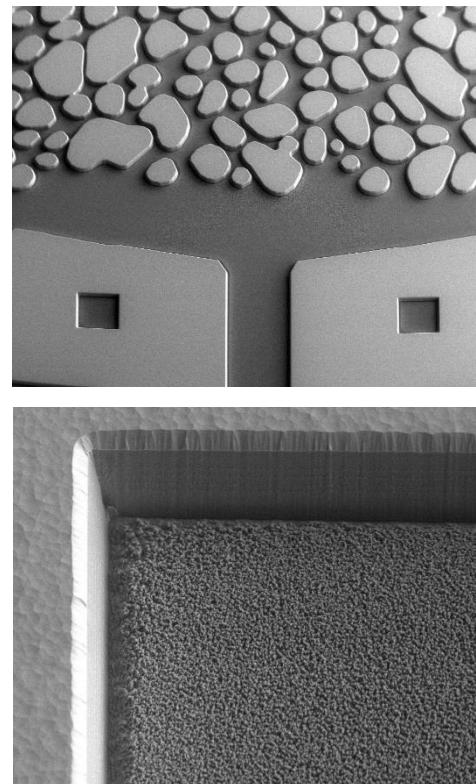
Many ways to machine transparent materials



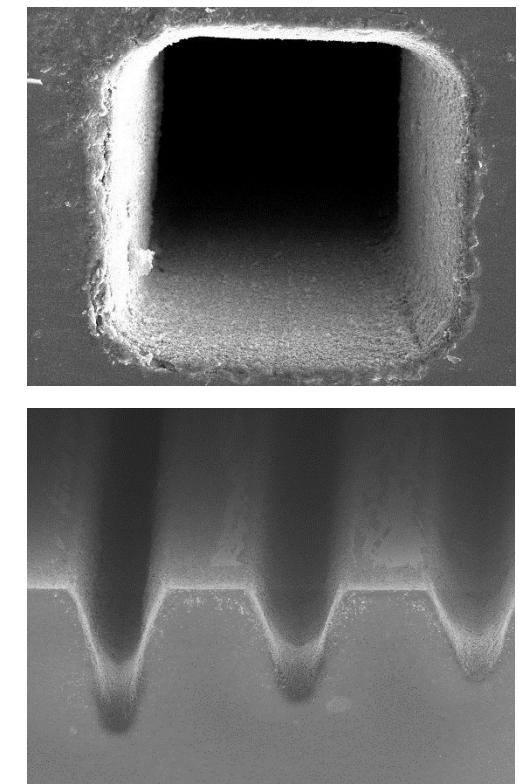
Dicing & thinning



Dry and wet etching



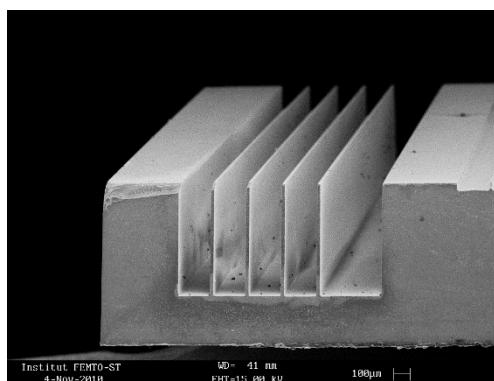
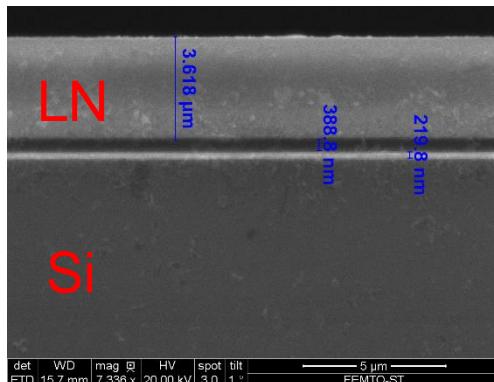
Laser machining



Micro-structuration of transparent materials



Dicing & thinning



Advantages

- Thinning until 1 μ m
- Optical roughness quality

- Aspect ratio>400
- Minimum width=1 μ m
- Sidewall verticality=88°
- Roughness quality=4nm

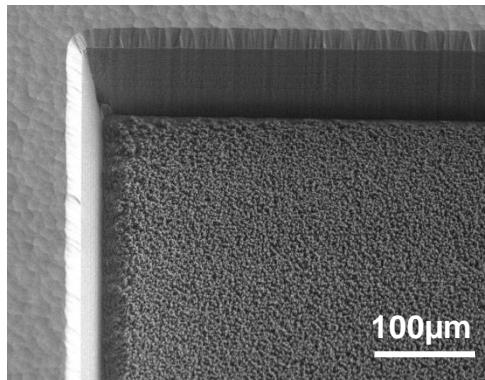
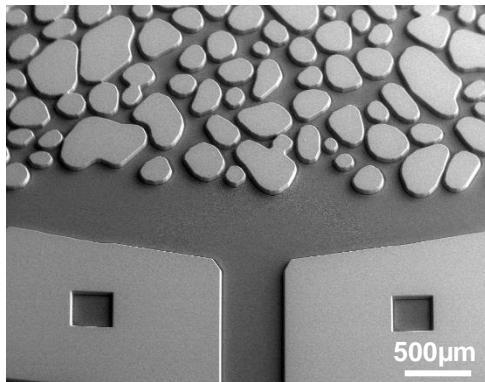
Drawbacks

- Thickness homogeneity>1 μ m
- Only straight lines are possible
- Maximum channel width=100 μ m

Micro-structuration of transparent materials



Dry and wet etching



Advantages

- Complex and deep etching are possible
- Anisotropic etching (Dry)
- Controlled roughness

Drawbacks

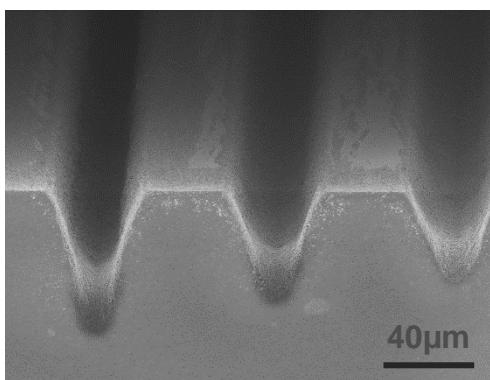
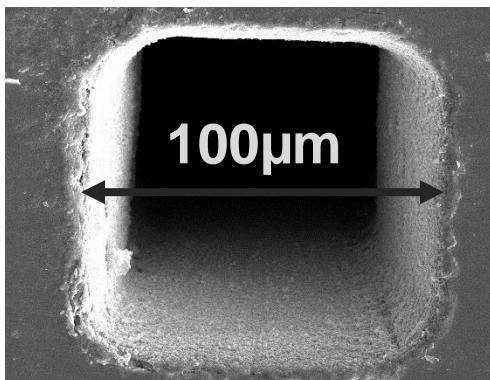
- Low aspect ratio
- Multistep process
- Sidewall verticality=80°

Micro-structuration of transparent materials



Case : Gaussian beam

Laser machining



Advantages

- Fast complex and deep etching are possible
- One step etching

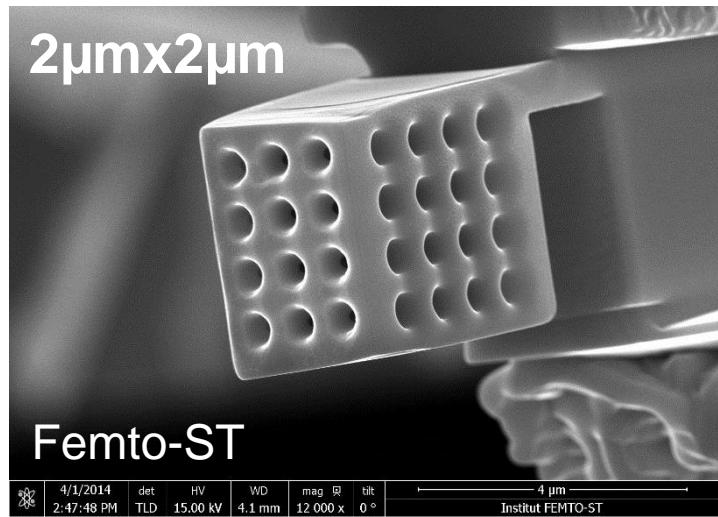
Drawbacks

- Low aspect ratio
- Roughness > 0,2µm
- Sidewall verticality = 75°

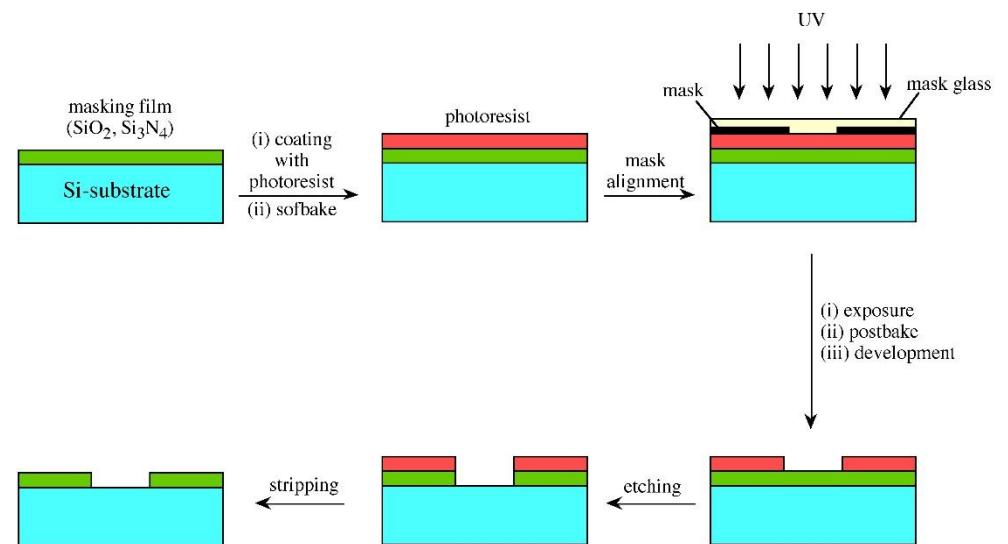
Nano-structuration of transparent materials



Focused ions beam



Clean room technology

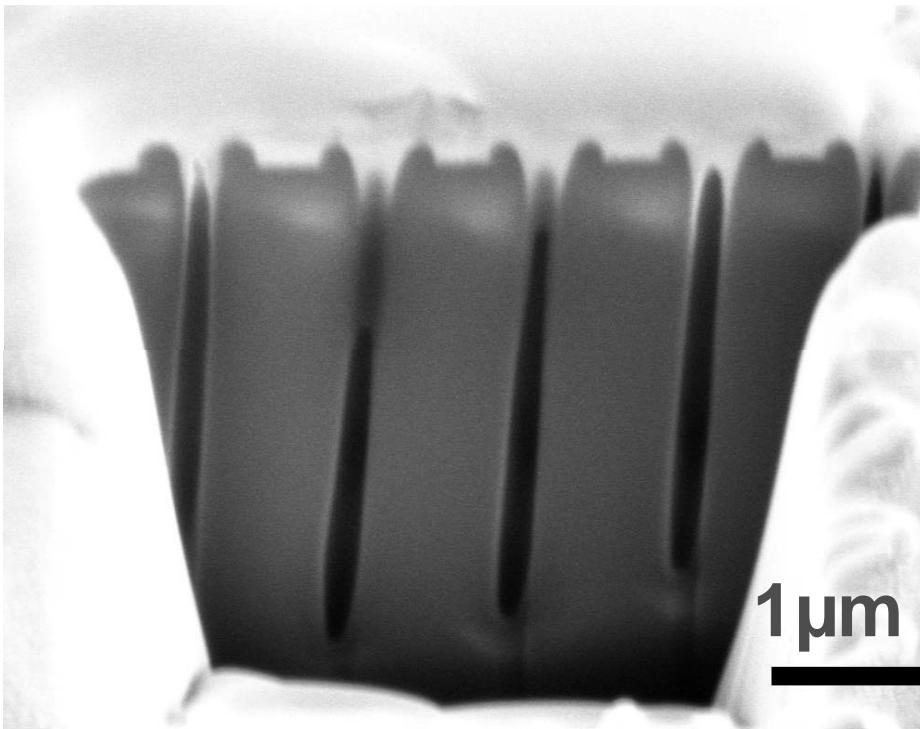


- Limited aspect ratio
- Very long time processing

Limits of classical femtosecond laser machining



Opt Exp 18, 16840 (2010)



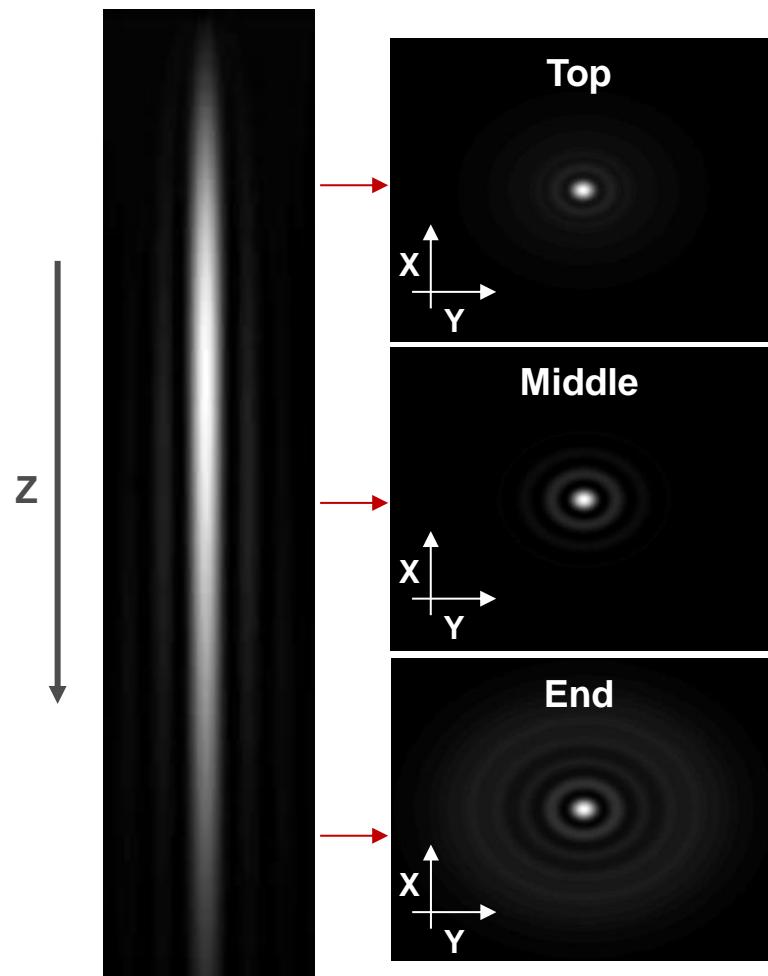
Low aspect ratio~20

High focusing



Machining deep ~ μm

Our technic : Bessel beams

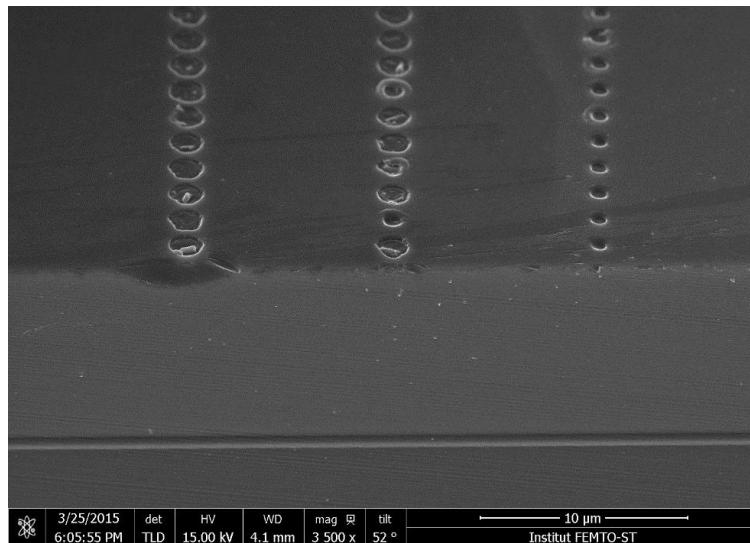


- Bessel beam diameter less than $1\mu\text{m}$
- Bessel length reaches several hundred microns
- High stability and homogeneity

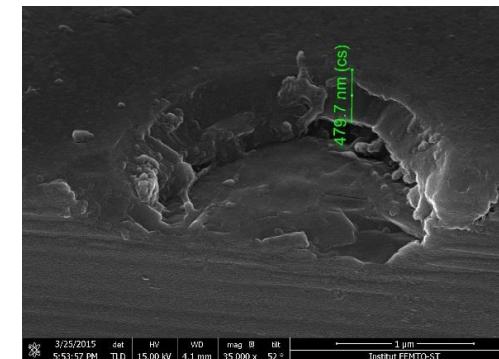
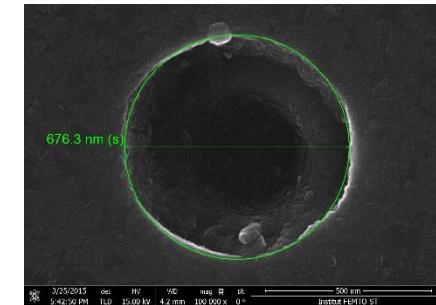
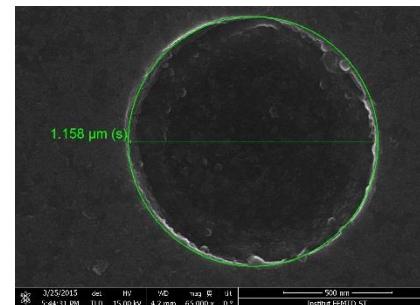
Nano-structuration by Bessel beams



➤ Lithium niobate



Perfect circle less than 1μm of diameter



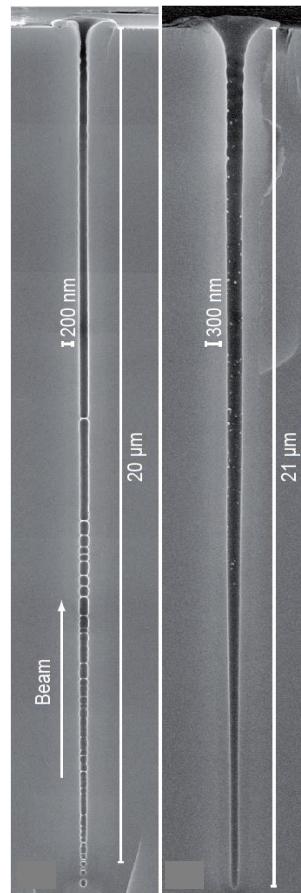
Surface nano-structuration

Depth less than 0,5μm

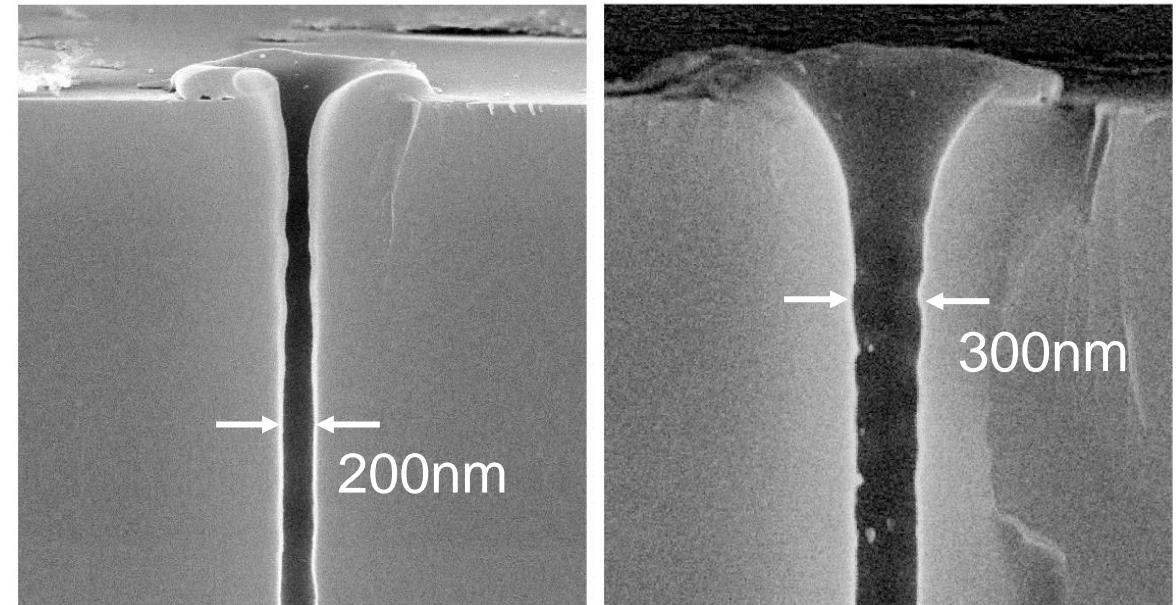
Nano-structuration by Bessel beams

femto
ENGINEERING

➤ Glass



one pulse=one channel



Aspect ratio =100

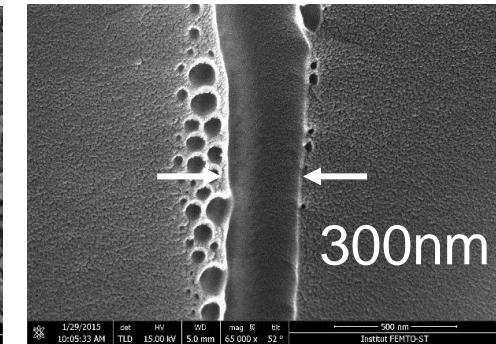
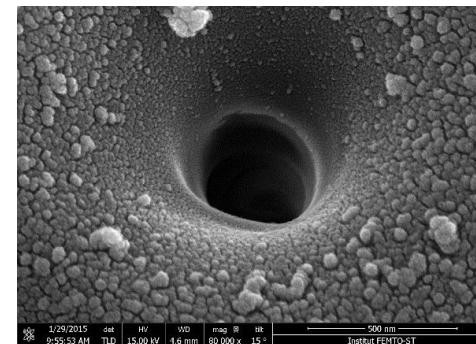
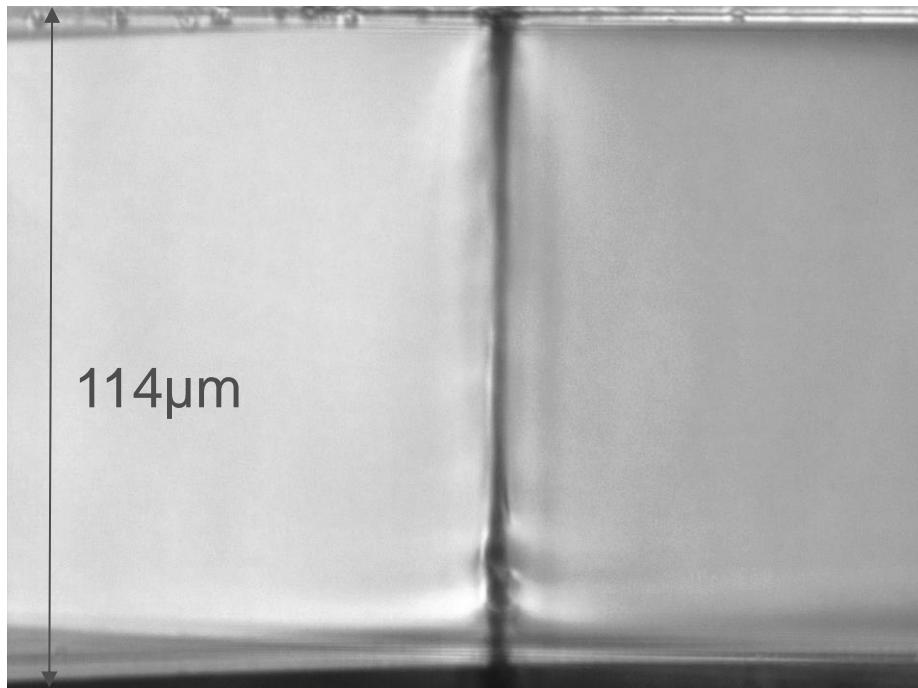
Bhuyan *et al*, Appl. Phys. Lett., 97, 081102 (2010)

Nano-structuration by Bessel beams



➤ Glass

one pulse = one channel



Aspect ratio=400

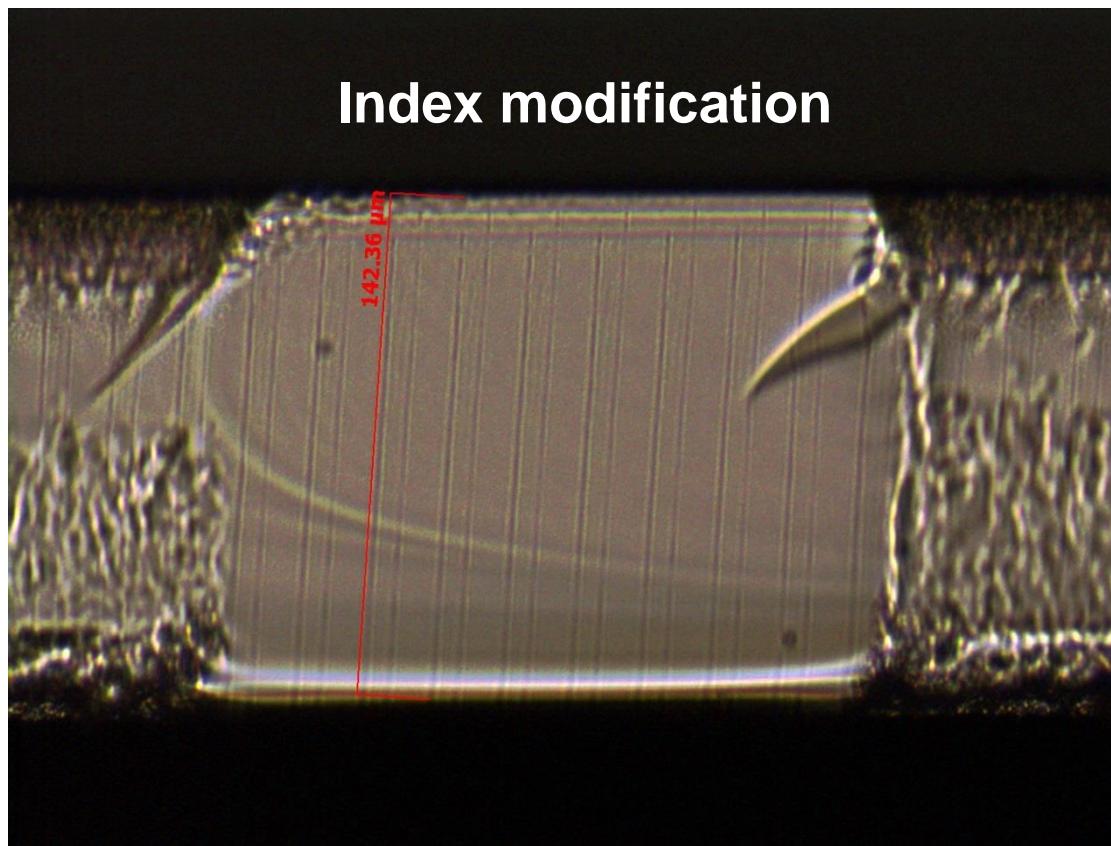
- The ablation rate per pulse is greater than $32\mu\text{m}^3$
- Gaussian beam $<2\mu\text{m}^3$

Nano-structuration by Bessel beams

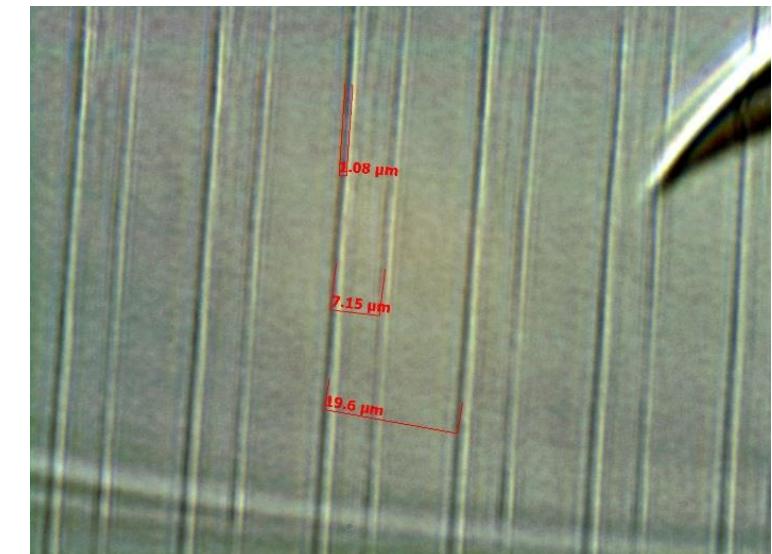
femto
ENGINEERING

➤ Glass

Index modification



Zoom



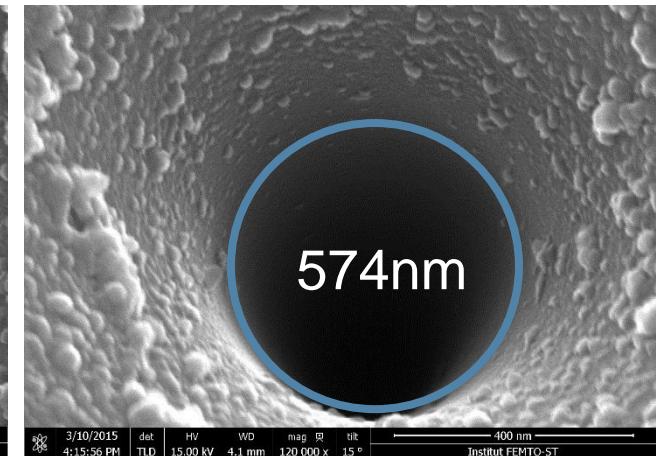
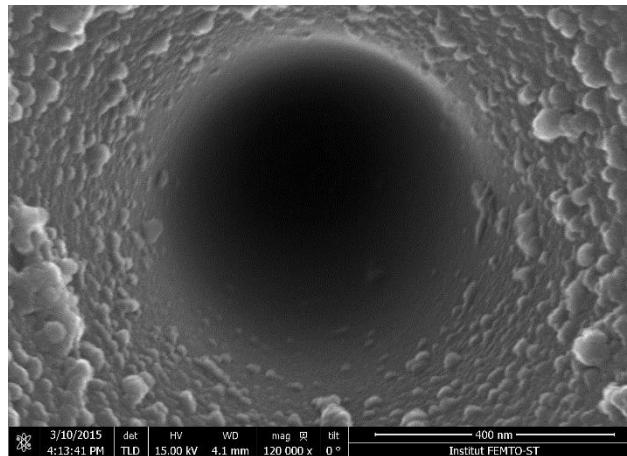
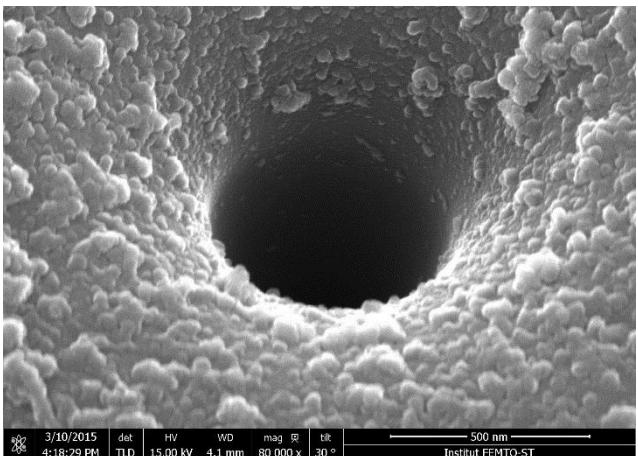
➤ Index modification can
be done until 2mm depth

Nano-structuration by Bessel beams

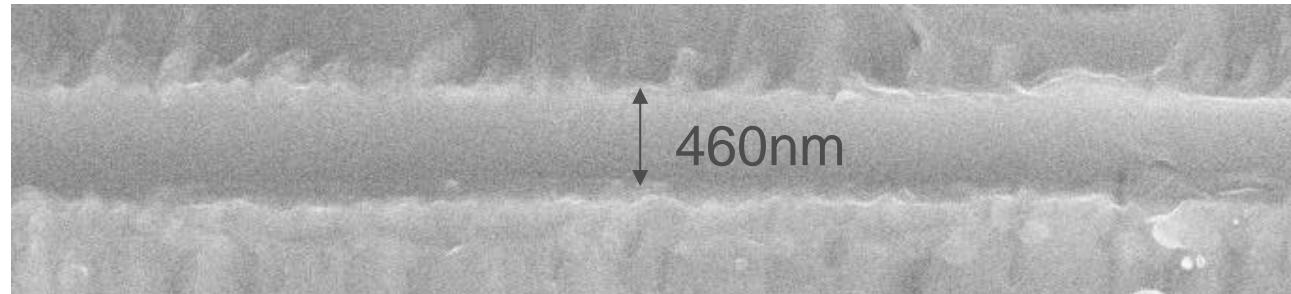


➤ Lithium niobate

Excellent surface quality : optical quality



Top view



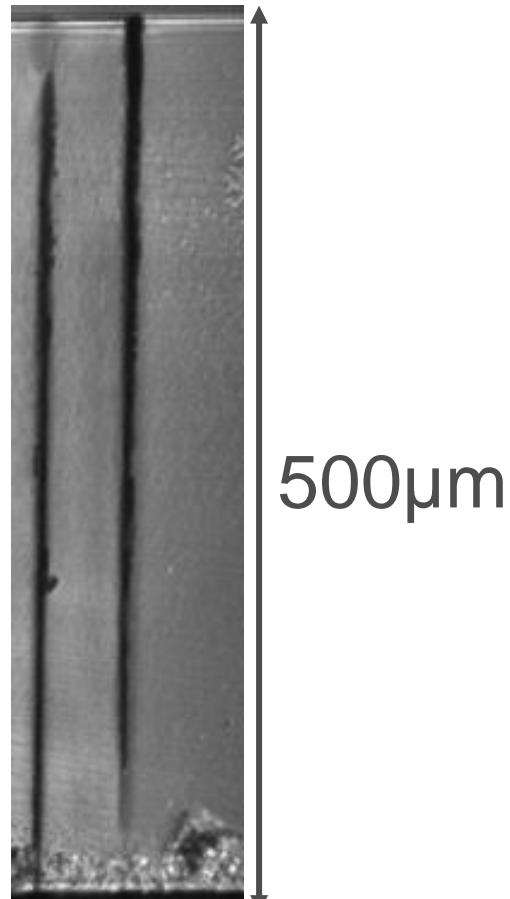
Inside channel view

Nano-structuration by Bessel beams

femto
ENGINEERING

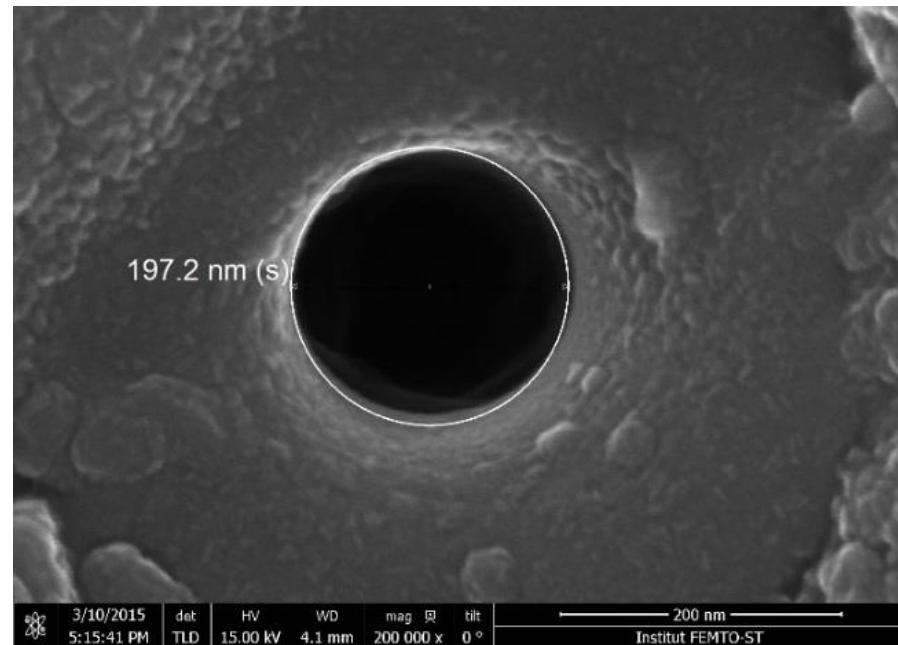
➤ Lithium niobate

OM picture



Side view

SEM picture



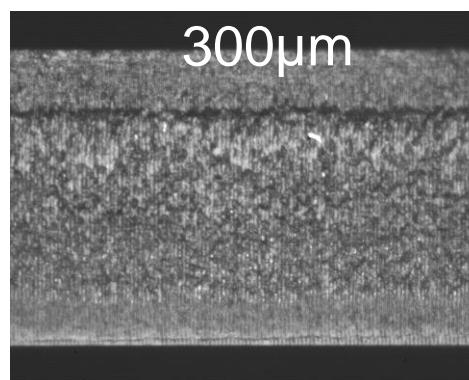
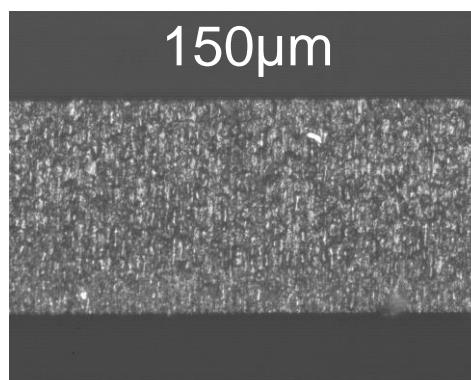
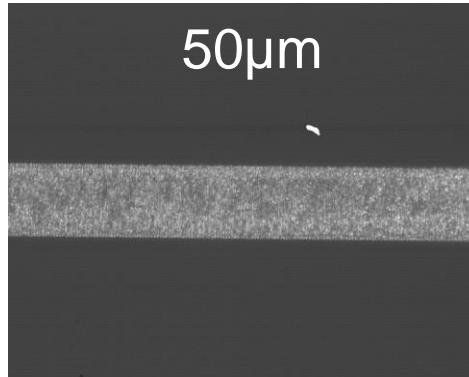
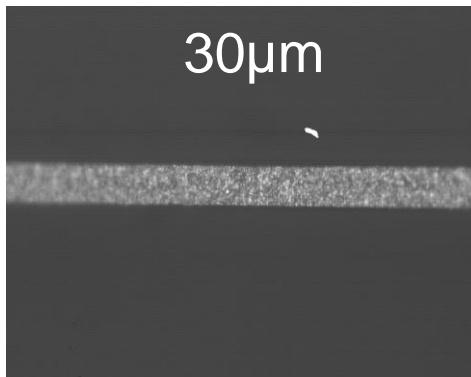
New record
Aspect ratio > 2000

Transparent materials laser cleaving



➤ Glass

V_{max}=100mm/s at low repetition rate

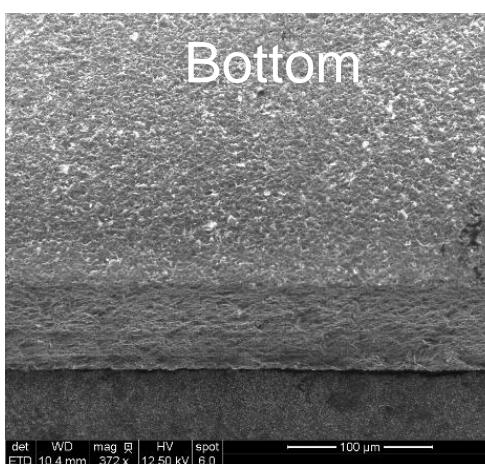
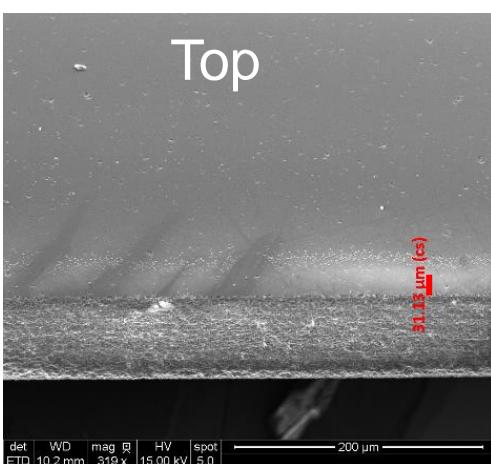
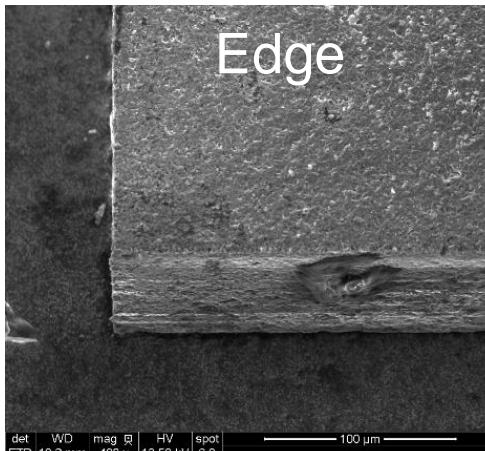
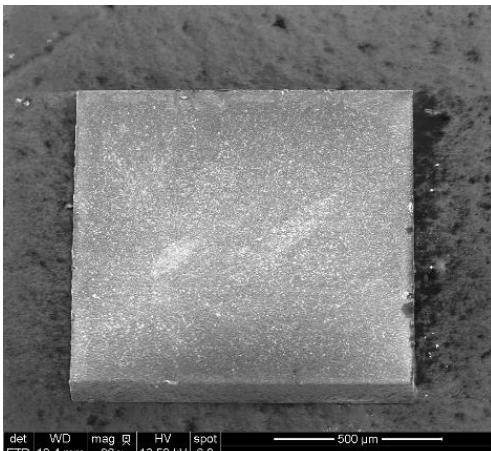


- Glass thickness range 30µm to 500µm
- Minimal micro-cracking<1µm
- Surface roughness, Ra < 1µm
- Speed cutting more than 1m/s is expected at high repetition rate

Transparent materials laser cleaving



➤ Quartz



Quartz high speed cutting

- Quartz thickness range 80μm to 500μm
- Very good surface quality
- Very good edge verticality
- Surface roughness, Ra < 2μm

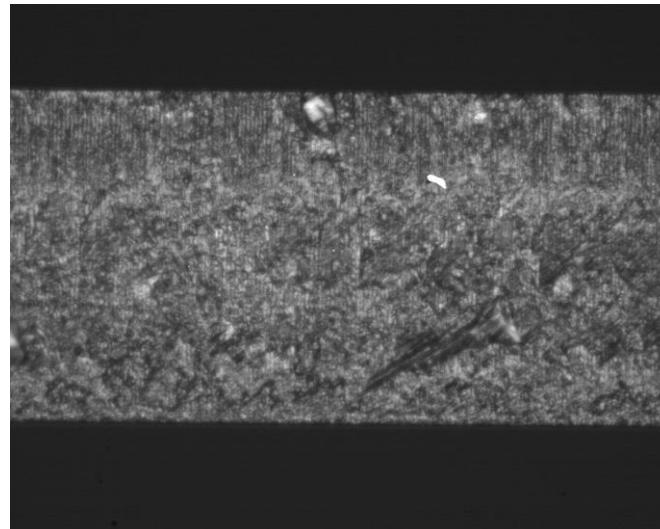
Transparent materials laser cleaving



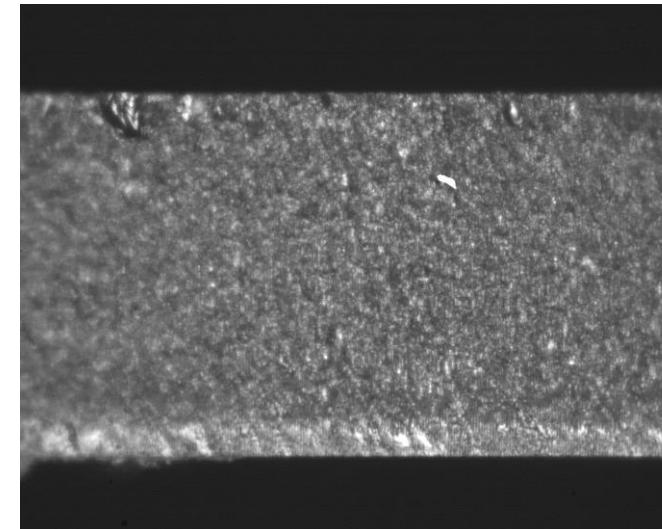
➤ Lithium niobate & Lithium tantalate

High speed crystals cutting

250µm



Lithium niobate



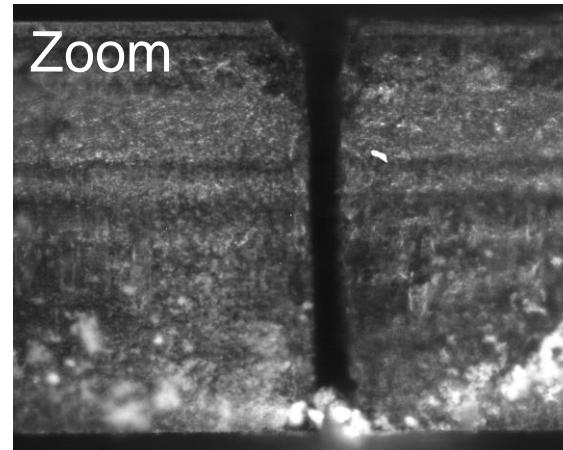
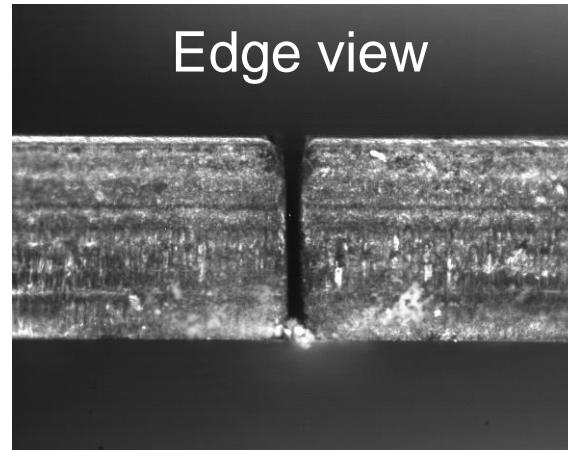
Lithium tantalate

Transparent materials laser machining

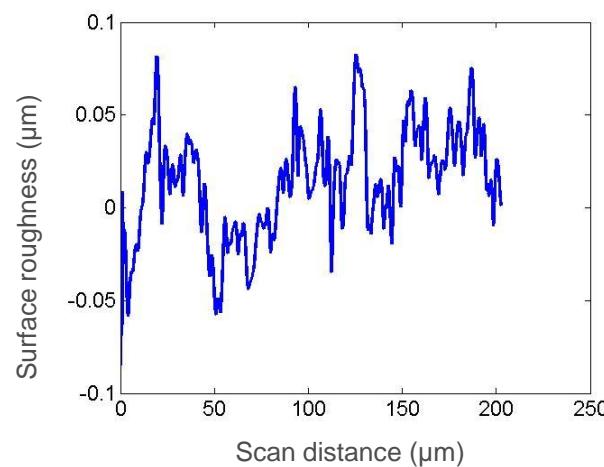
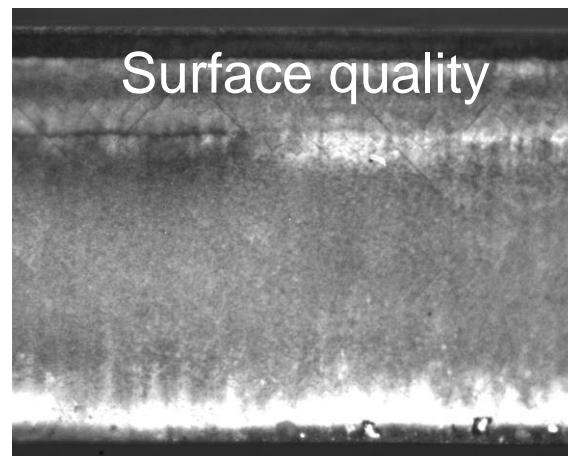


➤ Diamond

Diamond straight cutting



300µm



Ra~100nm

- Very high ablation rate $> 30\mu\text{m}^3$
- New aspect ratio record > 2000
- Possibility to nano-machine different kind of glass and crystals
- High speed laser glass and crystals cleaving



Thank you for your attention

- jassem.safioui@femto-st.fr
- [03 63 08 23 89](tel:0363082389)